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APPLICATION N	0.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,995	10/665,995 09/17/2003		Tai-Cheng Yu	6601	
25859	7590	11/01/2005		EXAM	INER
WEI TE	CHUNG		TON, ANABEL		
		IATIONAL, INC.	ART UNIT	PAPER NUMBER	
1650 MEI	MOREX DI	RIVE	ARTORIT	TATER NOMBER	
SANTA CLARA, CA 95050				2875	
				DATE MAILED: 11/01/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

EK

	Application No.	Applicant(s)					
Office Action Commons	10/665,995	YU ET AL.					
Office Action Summary	Examiner	Art Unit					
	Anabel M. Ton	2875					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1) Responsive to communication(s) filed on 10 Oc	ctober 2005.						
	action is non-final.						
3) Since this application is in condition for allowan	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠ Claim(s) <u>11 and 12</u> is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>11 and 12</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or election requirement.							
Application Papers							
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). 							
* See the attached detailed Office action for a list of the Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4)	(PTO-413)					

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DETAILED ACTION

1. Applicant's request for reconsideration of the finality of the rejection of the last Office action is persuasive and, therefore, the finality of that action is withdrawn.

Allowable Subject Matter

2. The indicated allowability of claims 11-12 is withdrawn in view of the newly discovered reference(s) to Yoshida et al (6,822,711). Rejections based on the newly cited reference(s) follow.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 11-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kretman et al. (6,497,946) in further view of Yoshida et al. (6,882,711).

Kretman discloses the claimed invention except for the recitation of the diffusion layer being a plate and specifically teaching the diffusion plate having light conversion elements. Kretman discloses a light guide plate (52), at least a light source disposed at a least one side of the light guide plate (54,), a diffusion film located above the light guide pate (60) and a reflection polarizer being located above the diffusion film (66) wherein the light guide the diffusion film and the reflection polarizer are stacked one on another in sequence. Yoshida

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discloses light conversion elements that are disposed on a surface of the diffusion plate and face towards the reflection polarizer (col. 17 lines 10-21,53-56)). It would have been obvious to one of ordinary skill in the art at the time the invention was made to substitute the diffusion layer of Kretman with that of Yoshida since Yoshida discloses the diffusion layer in one case as being a film having light scattering particles dispersed therein. This satisfies the limitation of the "light conversion elements disposed on a surface of the diffusion plate facing towards the reflection polarizer" since the light scattering particles are formed on an inner surface of the film subsequently facing the reflection polarizer. Furthermore the diffuser of Yoshida would have been purposeful to use the device of Kretman since a diffuser with light scattering particles throughout the diffuser will provide a greater amount of even light dispersion to the LCD of Kretman. With regards to the diffusion layer being a plate instead of a film, It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a plate instead of a film in the device of Kretman or Yoshida, since it has been held by the courts that, where the only difference between the prior art and the claims was a recitation of relative dimensions of the claimed device, and a device having the claimed relative dimensions would not perform differently than the prior art device, the claimed device was not patentably distinct from the prior art device. In Gardner v. TEC Systems, Inc., 725 F.2d 1338, 220 USPQ 777 (Fed. Cir. 1984), cert. denied, 469 U.S. 830, 225 USPQ 232 (1984). In this case a diffusion film would be desired because of its compact structure. With regards to method claim 12, the structural limitations of

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this claim are taught by the prior art as cited in this office action, therefore the above rejection applies.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anabel M. Ton whose telephone number is (571) 272-2382. The examiner can normally be reached on 08:00-16:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sandra O'Shea can be reached on (571) 272-2378. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect uspto gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (tollfree).

Anabel M Ton

Examiner

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AMT

Sandra O'Shea Supervisory Patent Examiner

Technology Center 2800